# MEASUREMENT OF THERMAL DIFFUSIVITY BY THE PHOTOACOUSTIC METHOD A computer simulation

## A. Hadj-Sahraoui<sup>1</sup>, A. Tahir<sup>1</sup>, G. Louis<sup>2</sup> and P. Peretti<sup>1</sup>

<sup>1</sup>Laboratoire de Physique et Biophysique, EA 228, Université René Descartes, Paris V <sup>2</sup>Département de Recherches Physiques, URA 71 CNRS, Université Pierre et Marie Curie, Paris VI, France

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## Abstract

Analysis of the photoacoustic signal vs. the modulation frequency allows the determination of thermal diffusivity. Computer simulations have been carried out to determine the optimal conditions, in the case of rear surface illumination, for which the thermal diffusivity is accurately measured. In accordance with these conditions, measurements were performed on a reference sample (silicon).

Keywords: photoacoustic method, thermal diffusivity

## Introduction

Photothermal techniques have been widely applied to the study of the optical properties and thermal parameters of liquids and solids [1, 2]. Several methods have been developed for the determination of thermal diffusivity [3]. The photoacoustic method we have used allows measurements of the thermal diffusivity through a sample. In this technique, the sample is enclosed in an air-tight cell and is excited by a chopped light beam. Light modulated at a frequency  $f=\omega/2\pi$  is absorbed and totally or partially converted into heat. As a result of the of periodic heating of the sample, the pressure in the cell oscillates at the chopping frequency; this is detected by a sensitive microphone coupled to the cell.

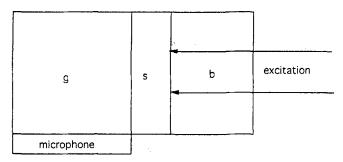
Frequency analysis of the photoacoustic signal in the case of the rear configuration leads to determination of the thermal diffusivity of the sample [4]. In such a configuration, the sample is heated by the modulated light source on one side and the temperature oscillations introduced are detected on the opposite side of the sample. The theoretical model of Rosencwaig and Gersho [5] shows that two conditions are necessary to measure the thermal diffusivity with precision: (i) the sample must be optically thick, and (ii) the sample must be thermally thick. In the present study, we specify the relations between the sample thickness, the optical absorption length and the thermal diffusion length which satisfy the two above-mentioned requirements and therefore allow an accurate measurement of the thermal diffusivity.

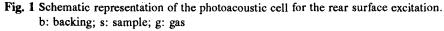
### Theoretical

In the theoretical model of Rosencwaig and Gersho [5], it is assumed that the amplitude and the phase angle of the pressure variation in the gas are determined by the temporal variation of the temperature distribution in the sample and gas, while the effect of thermal expansion of the sample is negligible, and the length of the gas column is much greater than the thermal diffusion length. Figure 1 schematically shows an idealized configuration of a photoacoustic cell. The sample of thickness  $l_s$  is mounted so that its rear surface is illuminated and the photoacoustic signal is detected by means of front microphonic detection. According to the one-dimensional model applied to the case of rear-surface illumination, the periodic pressure variation in the cell is given [5] by

$$\Delta P = \frac{\gamma P_o}{\sqrt{2} l_g a_g T_o} \Theta e^{j(\omega t - \pi/4)}$$
(1)

where  $\gamma$  is the ratio of the specific heats of the gas,  $P_o$  and  $T_o$  are the ambient pressure and the ambient temperature respectively,  $l_g$  is the thickness of the gas, and  $a_g$  is the inverse of the thermal diffusion length of the gas.





The term  $\theta$  is related to the optical, thermal and geometrical properties of the sample and to the backing and the gas media as follows:

$$\theta = \frac{\beta I_o}{2k_s(\beta^2 - \sigma_s^2)} \frac{2(r+g) - [(r+1)(g+1)e^{\sigma_s l_s} + (r-1)(g-1)e^{-\sigma_s l_s}]e^{-\beta l_s}}{(b+1)(g+1)e^{\sigma_s l_s} - (b-1)(g-1)e^{-\sigma_s l_s}}$$
(2)

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Here we define the following parameters:  $\beta$  is the optical absorption coefficient;  $I_o$  is the incident radiation intensity;  $\sigma_i = (1+j)/\mu_i$  where  $\mu_i = (\alpha_i/\pi f)^{1/2}$  denotes the thermal diffusion length in the material i;  $r = \beta/\sigma_s$ ;

$$b = \frac{k_b \sigma_b}{k_s \sigma_s} = \frac{\sqrt{k_b \rho_b c_b}}{\sqrt{k_s \rho_s c_s}}$$
 is the backing-effusivity-to-sample-effusivity ratio;

 $g = \frac{k_{g}\sigma_{g}}{k_{s}\sigma_{s}} = \frac{\sqrt{k_{g}\rho_{g}c_{g}}}{\sqrt{k_{s}\rho_{s}c_{s}}}$  is the gas-effusivity-to-sample-effusivity ratio;  $c_{i}$  is the

specific heat capacity at constant pressure of material *i*;  $k_i$  is the thermal conductivity of material *i*;  $\rho_i$  is the density of material *i*; and  $\alpha_i = k_i / \rho_i c_i$  is the thermal diffusivity of material *i*. The subscript *i* denotes *s* (sample), *g* (gas), and *b* (backing), respectively.

#### **Principle** of measurement

To determine the thermal diffusivity of the sample, the photoacoustic signal is analysed vs. the modulation frequency. For an optically opaque sample (i.e.  $l_s\beta >>1$ , r>>1), we can make the following approximations:

$$e^{-\beta \mathbf{L}} \approx 0; \ r+g \approx r; \ \frac{\beta}{\beta^2 - \sigma_s^2} \approx \frac{1}{\beta}$$

Equation (2) reduces to

$$\theta = \frac{1}{k_{s}\sigma_{s}} \frac{2I_{o}}{(b+1)(g+1)e^{\sigma_{s}\mathbf{l}} - (b-1)(g-1)e^{-\sigma_{s}\mathbf{l}}}$$
(3)

When the sample is also thermally thick (i.e.  $l_s >> \mu_s$ ),  $e^{-\sigma_s L} \approx 0$ , and we obtain

$$\theta = \frac{1}{k_{s}\sigma_{s}} \frac{2I_{o}e^{-\sigma_{s}l_{s}}}{(b+1)(g+1)}$$

$$\tag{4}$$

On substituting this expression into Eq. (1), we obtain

$$\Delta P = A e^{\mathbf{j}(\omega \mathbf{t} + \Phi)} \tag{5}$$

where A, the modulus of  $\Delta P$ , and  $\varphi$ , the phase angle, depend on the modulation frequency f as follows:

$$A = \frac{K}{f} \exp(-l_{\rm s}(\pi f / \alpha_{\rm s})^{1/2})$$

$$\varphi = -l_{\rm s}(\pi f / \alpha_{\rm s})^{1/2} - \pi / 2$$
(6)

$$K = \frac{\gamma P_o I_o \alpha_g^{\frac{1}{2}} \alpha_s^{\frac{1}{2}}}{\pi l_g T_o k_s (b+1)(g+1)}$$
(7)

where K is a term independent of frequency. Thus, the thermal diffusivity can be evaluated from modulation frequency analysis of either the signal amplitude or its phase.

#### Discussion

In the method presented here, we have shown that the thermal diffusivity can be determined under two conditions:

$$\mu_{\beta} \ll l_{s}$$
 (optically opaque sample) (8)

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$$\mu_s \ll l_s$$
 (thermally thick sample) (9)

Here,  $\mu_{\beta} = 1/\beta$  is the optical absorption length.

In order to obtain a sufficient photoacoustic signal, since we use rear-surface illumination, the sample thickness  $l_s$  must in any case be less than the sample thermal wavelength  $\lambda_s = 2\pi\mu_s$ . In the following, we determine the ratio  $\mu_s$  to  $l_s$  and the ratio  $\mu_\beta$  to  $l_s$  so that the inequalities [8] and [9] are satisfied and, therefore, the simplifications of Eq. (2) are valid. To this end, we use simulations of photoacoustic data for samples with known thermal diffusivity.

#### a. Comparison between $l_s$ and $\mu_s$

Using Eq. (2) (i.e. the expression not simplified with  $\Delta P$ ), we have calculated the amplitude A of the photoacoustic signal for a silicon sample. Calculations were made with the known thermal diffusivity of silicon,  $\alpha_s = 0.91 \cdot 10^{-4} \text{ m2/s}$ . The reference value for the sample thickness is  $l_s = 2 \text{ mm}$ ; the backing and the gas in the cell are air ( $\alpha_g = \alpha_b = 2.15 \cdot 10^5 \text{ m}^2/\text{s}$ ,  $k_g = k_b = 0.026 \text{ W m}^{-1}\text{K}^{-1}$ ). The value of the optical absorption coefficient  $\beta$  is chosen to be equal to  $10^7 \text{ m}^{-1}$  ( $\mu_{\beta} = 1/\beta =$ 0.1 µm) so that the first condition,  $\mu_{\beta} < l_s$ , is satisfied and, therefore, the first simplification of Eq. (2) is valid.

For different modulation frequency ranges (i.e. for different values of  $\mu_s$ ), we plotted ln(Af) as a function of (f)<sup>1/2</sup> (Fig. 2) and deduced the sample thermal diffusivity from the slope of the curve. Table 1 lists values of thermal diffusivity obtained from simulated data for three frequency ranges corresponding to different ratios  $l_s$  to  $\mu_s$ .

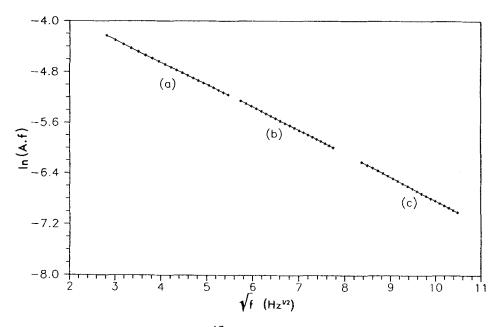


Fig. 2 Theoretical plots of  $\ln(Af)$  vs.  $f^{1/2}$  for different frequency ranges with  $l_s = 2$  mm,  $\alpha_s = 0.91 \cdot 10^{-4} \text{ m}^2/\text{s}$  and  $\beta = 10^7 \text{ m}^{-1}$ 

As this ratio increases, the relative error  $\Delta \alpha_s/\alpha_s$  as concerns the expected value of  $\alpha_s$  decreases. A correct value of thermal diffusivity ( $\Delta \alpha_s/\alpha_s < 3\%$ ) is reached when the frequency range is such that  $l_s > 2\mu_s$ . This means that the condition  $l_s >> \mu_s$  (thermally thick sample) reduces in fact to  $l_s > 2\mu_s$ .

**Table 1** Thermal diffusivity  $\alpha_s$  of the sample obtained for different modulation frequency ranges

f / Hz	<i>l</i> , / mm	$\alpha_s / m^2 \cdot s^{-1}$	$\Delta \alpha_{s} \cdot \alpha_{s}^{-1} / \%$
8 <f<27< td=""><td><math display="block">\mu_{\rm s} &lt; l_{\rm s} &lt; 2\mu_{\rm s}</math></td><td>1.040×10<sup>-4</sup></td><td>14.50</td></f<27<>	$\mu_{\rm s} < l_{\rm s} < 2\mu_{\rm s}$	1.040×10 <sup>-4</sup>	14.50
32 < f < 60	$2\mu_{\rm s} < l_{\rm s} < 3\mu_{\rm s}$	0.930×10 <sup>-4</sup>	2.13
70 < f < 110	$3\mu_{s} < l_{s} < 4\mu_{s}$	0.905×10 <sup>-7</sup>	0.47

#### b. Comparison between $l_s$ and $\mu_\beta$

For a given value of  $l_s$  (2 mm), we calculated  $\ln(Af)$  as a function of  $(f)^{1/2}$  in the frequency range so that  $l_s>2\mu_s$  (i.e. the condition required for Eq. (4) is satisfied). This is plotted in Fig. 3. Table 2 lists the values of thermal diffusivity obtained for different values of  $\mu_{\beta}$ . It can be observed that for  $\beta=2\cdot10^3$  m<sup>-1</sup> the curve is not linear. This means that the condition  $\mu_{\beta}<< l_s$  required in arriving at

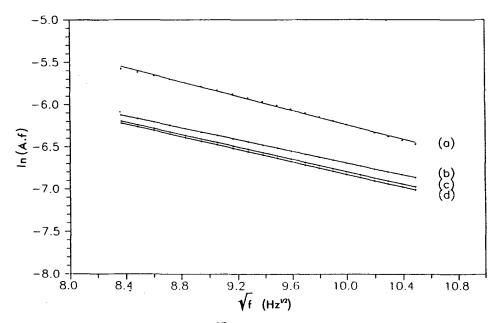


Fig. 3 Theoretical plots of  $\ln(Af)$  vs.  $f^{1/2}$  in a frequency range so that  $l_s>3 \mu_s$ . The sample thickness is  $l_s=2$  mm, its diffusivity  $\alpha_s=0.91 \cdot 10^{-4}$  m<sup>2</sup>/s and its optical absorption coefficients are: (a)  $\beta=2\cdot 10^3$  m<sup>-1</sup>, (b)  $\beta=5\cdot 10^3$  m<sup>-1</sup>, (c)  $\beta=10^4$  m<sup>-1</sup>, (d)  $\beta=5\cdot 10^4$  m<sup>-1</sup>

Table 2 Thermal diffusivity  $\alpha_s$  obtained for different values of the optical absorption coefficient  $\beta$ 

β / m <sup>-1</sup>	μ <sub>β</sub> / mm	$\alpha_{\rm s}$ / m <sup>2</sup> ·s <sup>-1</sup>	$\Delta \alpha_{s} \cdot \alpha_{s}^{-1} / \%$
2×10 <sup>3</sup>	0.2	1.04×10 <sup>-4</sup>	14.4
10 <sup>4</sup>	0.1	0.93×10 <sup>-4</sup>	3.1
5×10 <sup>4</sup>	0.02	0.90×10 <sup>-4</sup>	0.4

Eq. (3) is not satisfied. For the other values of  $\beta$ , the curve is linear and the thermal diffusivity is obtained with higher precision when  $\beta$  increases. The precise value of  $\alpha_s$  is reached when  $l_s \ge 100 \ \mu_{\beta}$ . Then, the sample can be assumed to be optically thick.

### **Experimental and discussion**

We used a modulated beam from a 514.3 nm argon laser of 100 mW power to heat the sample. The sample was placed in a photoacoustic cell 30 mm in diameter and 8 mm in length. We used disk-shaped silicon samples 30 mm in diameter and 1.5-3 mm thick. The sample was attached to a sample holder and

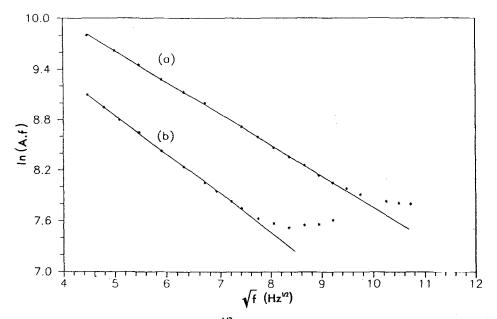


Fig. 4 Experimental plots of  $\ln(Af)$  vs.  $f^{1/2}$  for (a) the 2 mm-thick silicon sample and (b) 2.5 mm-thick silicon sample

its backing material was air. The amplitude of the photoacoustic signal obtained with a two-phase locking amplifier was recorded as a function of modulation frequency f. Finally, the experimental curves were fitted by means of a least-square program.

The optical absorption coefficient of silicon for the incident radiation is  $\beta = 7.3 \cdot 10^5 \text{ m}^{-1}$ ; the corresponding length of optical absorption is  $\mu_{\beta} = 1.37 \mu m$ , and therefore the conditions  $l_s > 100 \mu_{\beta}$  is satisfied for the samples used. The experiments were carried out in a modulation frequency range such that the conditions  $l_s > 2\mu_s$  was satisfied for each sample.

In the case of the 2 mm-thick sample, as an example, this condition is satisfied for f>30 Hz. Figure 4(a) shows the variation in  $\ln(Af)$  as a function of  $(f)^{1/2}$  for the 2 mm-thick sample. The graph exhibits two different parts: linear behaviour for f<85 Hz, and non-linear behaviour for f>85 Hz. The thermal diffusivity of the silicon sample was determined from the slope of the linear part of the curve: we found  $\alpha_s = 0.89 \cdot 10^{-4} \text{ m}^2/\text{s}$ . This value agrees very well with literature data [6]. Different experiments performed under the same conditions reveal the good reproductibility of the slope measurements. The incertitude in  $\alpha_s$  determination is mainly due to the sample thickness measurements. It is estimated to be 20 µm, which leads to a precision of about 1%.

The non-linear behaviour of the curve for the higher frequency is explained [4] by the contribution to the photoacoustic signal from the thermoelastic bend-

ing of the embedded sample. This effect is related to the temperature gradient set within the sample along the thickness direction. The vibrating sample acts as a mechanical piston, thereby contributing to the pressure variation. To minimize this mechanical contribution, the sample must lean against a solid transparent backing.

From Eq. (7), it can be seen that analysis of the signal phase vs. the modulation frequency also allows determination of the thermal diffusivity. However, no measurements of  $\alpha_s$  have been performed with signal phase  $\Phi$  analysis. This is mainly due to the fact that the signal to noise ratio becomes relatively important in the frequency range where the condition  $l_s>2 \mu_s$  is satisfied.

Through analysis of the signal amplitude A vs. modulation frequency f, the photoacoustic technique allows determination of the thermal diffusivity of optically and thermally thick samples. It has been shown that these conditions are expressed through two well-defined relationships between the sample thickness and the optical absorption length on one hand and between the sample thickness and the thermal diffusion length on the other hand.

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Zusammenfassung — Die Analyse des fotoakustischen Signales in Abhängigkeit von der Modulierungsfrequenz erlaubt die Feststellung des thermischen Diffusionsvermögens. Für den Fall einer Oberflächenbestrahlung, für die das thermische Diffusionsvermögen präzise vermessen wurde, ergaben Computersimulationen die optimalen Bedingungen. In Übereinstimmung mit diesen Bedingungen wurden Messungen an einer Referenzprobe (Silikon) durchgeführt.